## **Supporting information**

## Enhanced thermal shock resistance of ultra-high temperature ceramic by biomimetic surface modification

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**Fig. S1** Mapping images of elements distribution. (a) A cross-sectional SEM image of specimen with coating. (b-f) The mapping images of B, C, O, Si and Zr elements for specimen with YSZ coating, respectively.



**Fig. S2** Typical top SEM images of the first (a) and second (b) round dip-coating and calcination at 600 °C, respectively.



**Fig. S3** TEM images of YSZ powders. (a) The typical conventional TEM bright fields of the YSZ powders and the SAED pattern (the inset). (b) A HR-TEM image taken from the same area. (c) Energy-dispersive analysis microscope (EDAM) of YSZ coating.



Fig. S4 TG and DSC curves of YSZ gel.



**Fig. S5** The digital camera images of deionized water drops on the samples with (a) and without nanostructures (b), respectively.



**Fig. S6** The typical optical images of  $ZrB_2$  ceramic matrix composite (a), oxidation at 900 °C for 1 h (b), alkali treatment with concentrated  $NH_3 \cdot H_2O$  and  $H_2O_2$  at 90 °C for 1 h (c), the third dipcoating and calcination at 600 °C (d).